

WHAT IS CLAIMED IS:

1. A damping and muffling structure for EL cell, comprising a transparent substrate, a front electrode layer, a lighting layer, an inducing layer, a back electrode layer and an insulating layer for packaging the EL cell, the front electrode layer, lighting layer, inducing layer, back electrode layer and insulating layer being sequentially overlaid on the substrate, a conductive layer being laid between the lighting layer and the inducing layer, the front and back electrode layers and the conductive layer being connected to a driving circuit having a grounding electrode, the conductive layer being connected to the grounding electrode of the driving circuit, whereby the conductive layer can conduct the charge accumulating on the inducing layer to the grounding electrode.
2. The damping and muffling structure for EL cell as claimed in claim 1, wherein the conductive layer is made of conductive material such as silver gum, carbon gum, metal and conductive polymer.
3. The damping and muffling structure for EL cell as claimed in claim 1, wherein the conductive layer is laid along one side of the inducing layer.
4. The damping and muffling structure for EL cell as claimed in claim 1, wherein the conductive layer is laid along at least two sides of the inducing layer.
5. The damping and muffling structure for EL cell as claimed in claim 1, wherein the front and back electrode layers and the conductive layer

respectively have three outward extending conductive terminals for connecting with the driving circuit.